

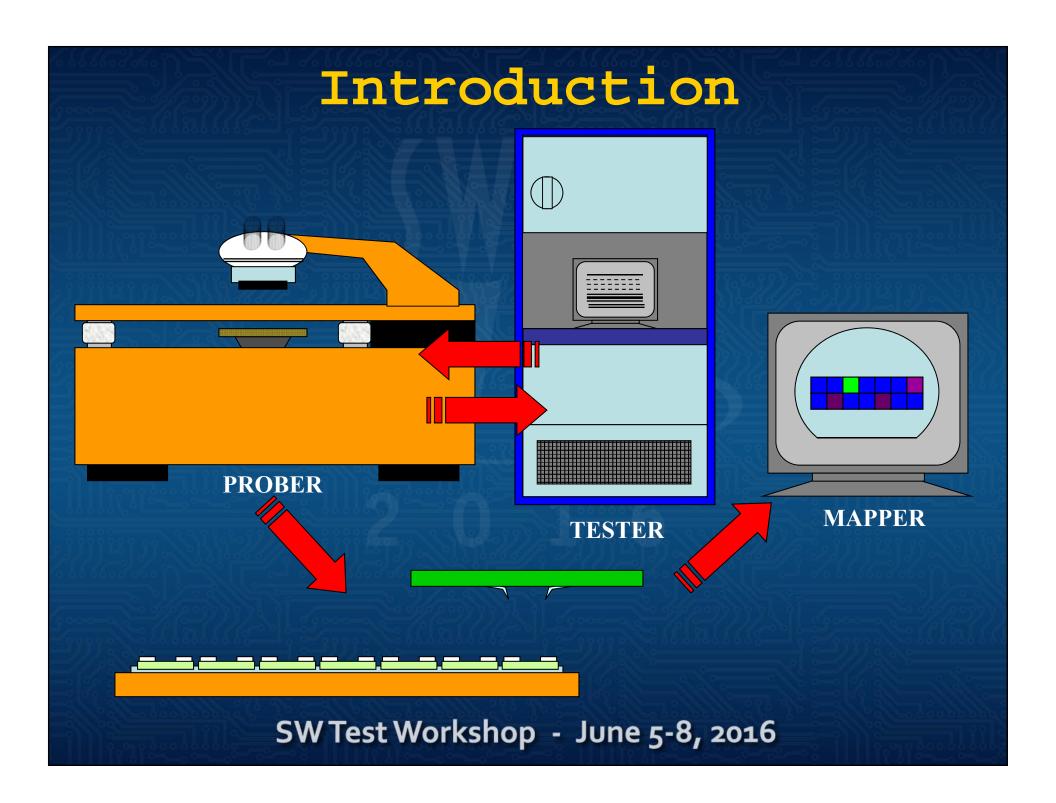
SW Test Workshop Semiconductor Wafer Test Workshop

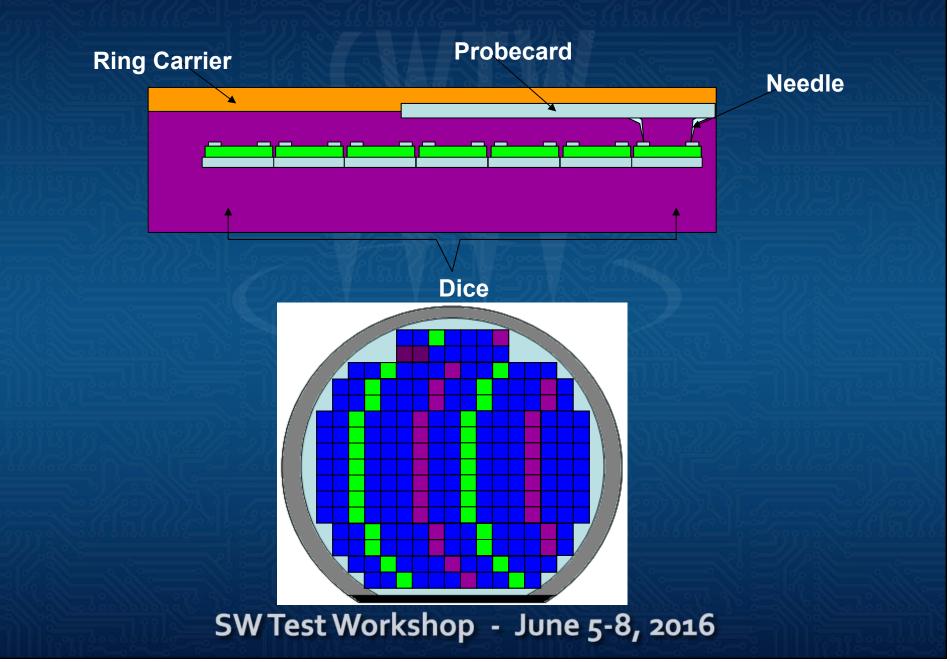
Understanding the Probe Damage Risk thru Determination of Minimum Bond Pad Opening Capability of Different Prober and Needle Type Set-up



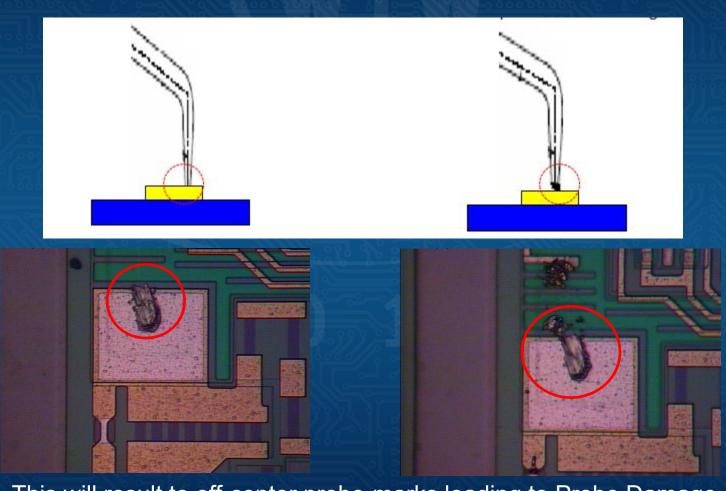
Wiljelm Carl K. Olalia

Process Engineer II
Probe and Die Sales Department
ON Semiconductor Philippines
June 5-8, 2016





What happen when Probe Needle is off-center?



This will result to off-center probe-marks leading to Probe Damage.

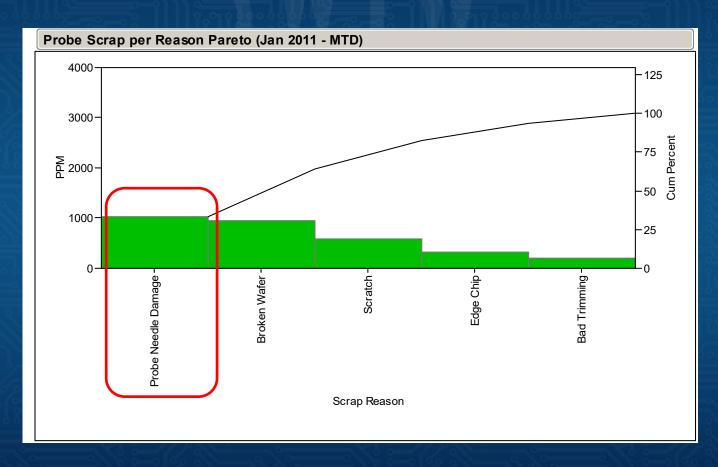
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What is Probe Damage ?

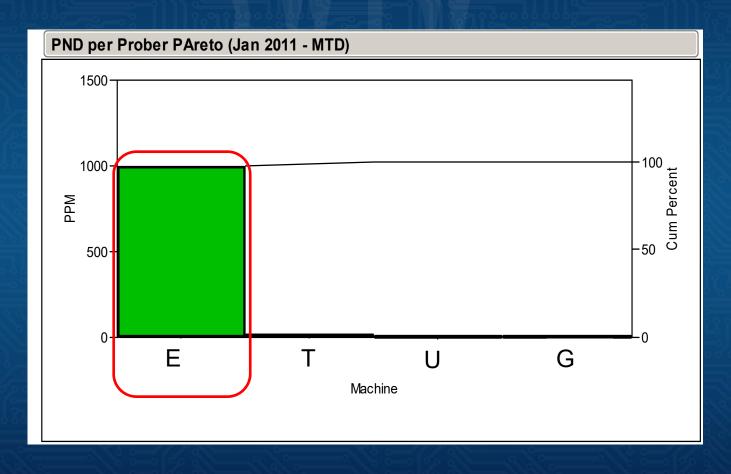
- Is a phenomena when a part of a die specifically at the Pad Area such as Seal Ring or other metallization has been damage by the Probe Needle during Testing.
- Probe damage is the number one visual defect contributor at wafer sort process having a direct impact on yield and cycle time.

No	Defect visual aid	Remarks
1	REJECT	Probe marks touching the seal ring of the bond pad
2		Expose oxide on the bonding pad

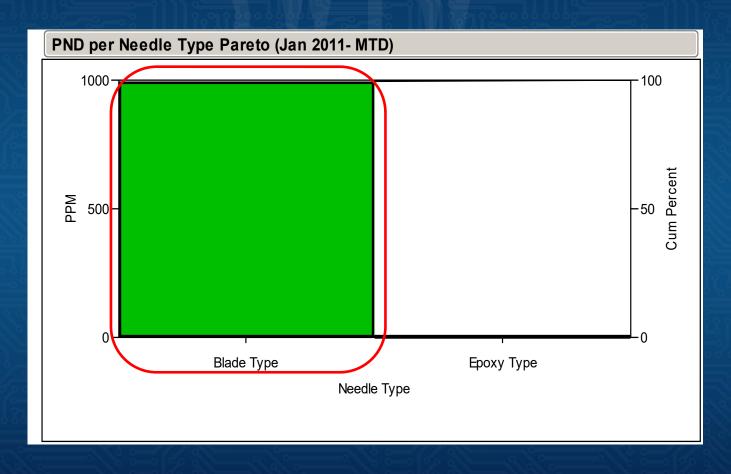
At 1000 ppm, Probe Damage related to Probe Needle is on top of Pareto in terms of wafer scrappage reason.



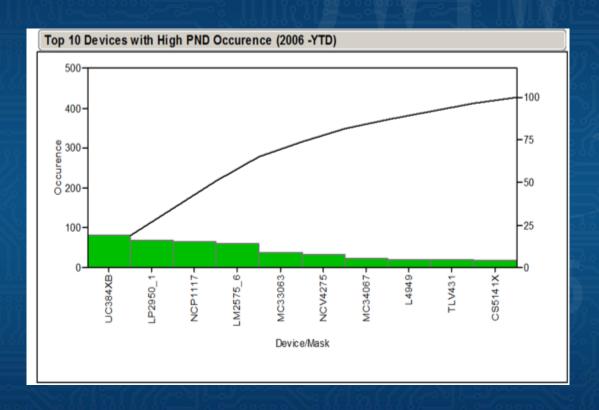
100% of those 1000 ppm have been contributed by the Prober E which uses a Blade Type Needle for Probing.



100% of those 1000 ppm have been contributed by the Prober E which uses a Blade Type Needle for Probing.



Further data stratification shown Top Devices with high Probe Damage Occurrence



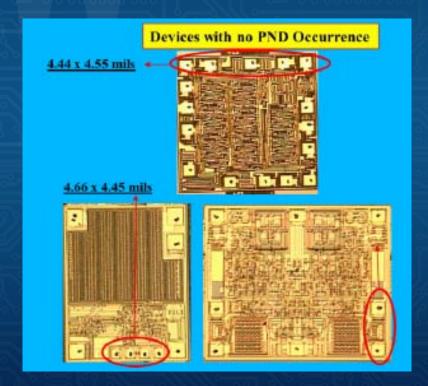
Mask Name	Total Occurrence		Small Pad Size	Big Pad Size		
UC384XB	81		3.6 x 4.1 mils	4.2 x 4.2 mils		
LP2950_1	69		3.5 x 4.0 mils	4.2 x 4.1 mils		
NCP1117	66		4.1 x 3.4 mils	7.7 x 6.3 mils		
LM2575_6	61		3.3 x 3.2 mils	7.6 x 7.3 mils		
MC33063	39		3.4 x 4.0 mils	4.2 x 4.2 mils		
NCP5331	36		3.4 x 3.4 mils	4.0 x 3.8 mils		
NCV4275	32		3.7 x 3.6 mils	6.0 x 5.8 mils		
NCP5422	24		3.6 x 3.5 mils	4.0 x 4.0 mils		
MC34067	23		3.5 x 4.0 mils	4.3 x 4.1 mils		
L4949	21		3.3 x 3.2 mils	4.8 x 4.4 mils		
TLV431	19		3.1 x 3.1 mils			
CS5141X	17		4.3 x 4.1 mils			

Devices with high PND occurrence have an average bond pad size less than 4 x 4 mils compared with devices with no PND occurrence. Initial assumption on high PND occurrence is due to Prober X when using blade type needle is not capable of probing devices with a minimum

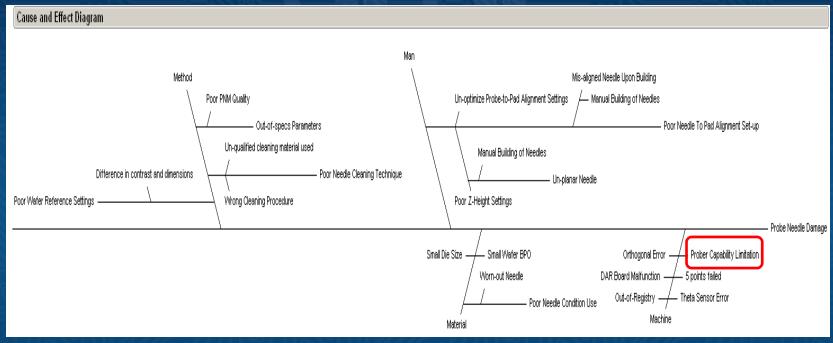
Devices with high PND Occurrence

3,96 x 3.88 mils

4.0 x 3.5 mils



What are the causes Probe Damage ?



- > Probe Capability limitation in terms of minimum bond pad opening has been identified as one of the many causes of Probe Damage on wafers.
- > Smaller pad is high risk to Probe Damage.

Objective/Goals

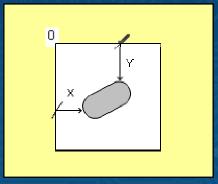
- To determine the different minimum bond pad opening capability at Probe using different Prober and Needle Type.
- To assess the Probe Damage risk and come up with a solution to reduce the risk.

- Identify all possible Prober and Needle Type Combination.
 - ➤ Block all the other factors that will serve as noises. This is to eliminate the un-necessary variation that will affect the overall accuracy of the study.
- Create a Data Collection Plan
- Perform Data Analysis
- Perform Capability Study
- Risk Assessment

- I. Old Prober Tandem with Blade Type Needle
- II. Old Prober Tandem with Epoxy Type Needle
- III. New Prober Tandem with Blade Type Needle
- IV. New Prober Tandem with Epoxy Type Needle
- V. New Prober Tandem with Vertical Type Needle

Data Collection Plan:

1. Measure the Length X & Y value as shown in Figure 1. Perform measurements on dice illustrated in Figure 2.



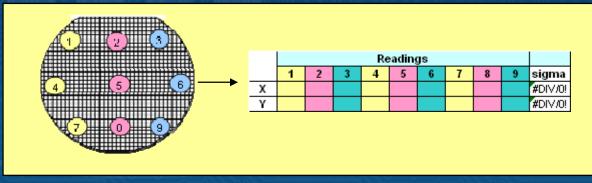
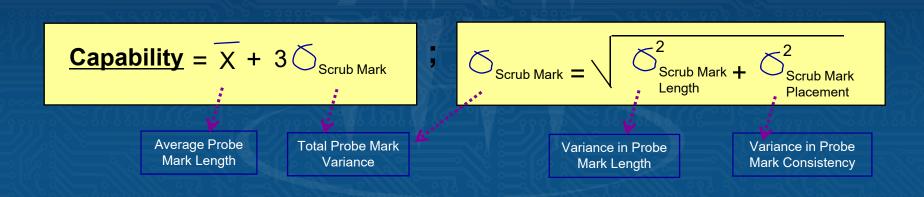


Fig 1

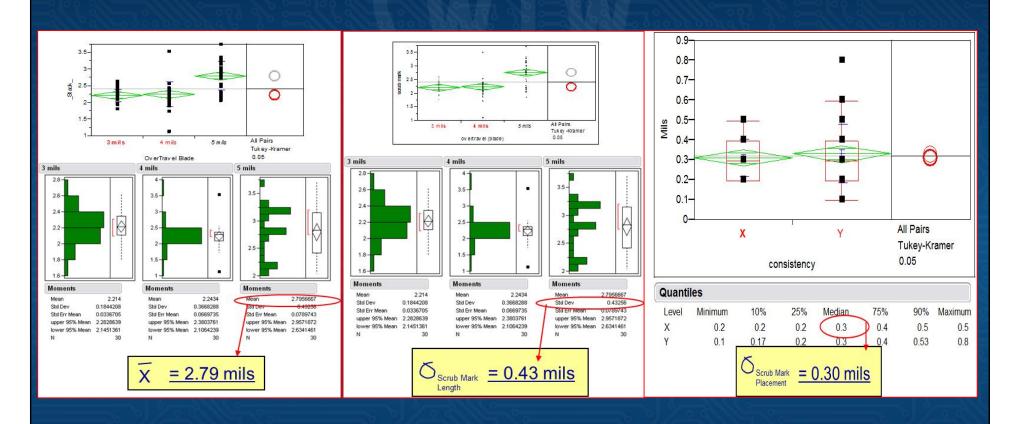
2. Repeat # 1 until 30 data sets is achieved.

Computation of Minimum Bond Pad Capability using "Components of Variation":



Capability Assessment

I. Old Prober Tandem with Blade Type Needle



Capability Assessment

I. Old Prober Tandem with Blade Type Needle

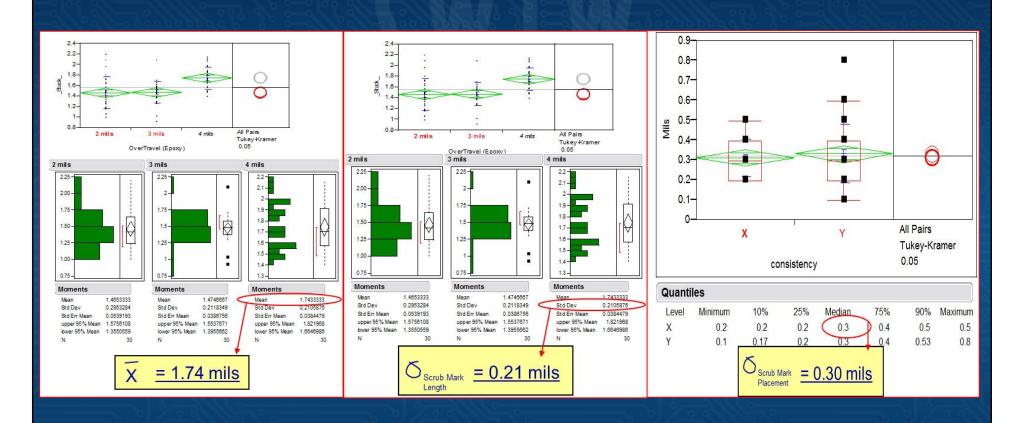
$$\underline{\mathbf{Capability}} = \overline{\mathbf{X}} + 3 \mathcal{O}_{\mathsf{Scrub}\,\mathsf{Mark}}$$

Capability =
$$2.79 + 3 \bigcirc_{Scrub Mark}$$
; $\bigcirc_{Scrub Mark} = 0.5264$

Capability =
$$\frac{2.79}{2.79}$$
 + $3(0.5264)$

Capability = 4.37mils
$$\approx$$
 4.5 mils

II. Old Prober Tandem with Epoxy Type Needle



II. Old Prober Tandem with Epoxy Type Needle

Capability =
$$\overline{X} + 3 \bigcirc_{Scrub Mark}$$

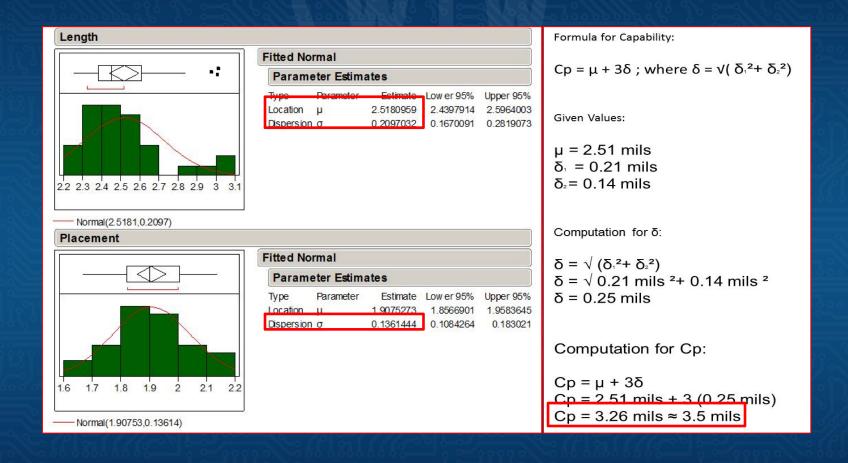
Scrub Mark =
$$\sqrt{\sum_{\text{Scrub Mark + } \text{Eength}}^{2}} \sqrt{\sum_{\text{Scrub Mark Placement}}^{2}}$$

Capability =
$$1.74 + 3 \circlearrowleft_{Scrub Mark}$$
; $\circlearrowleft_{Scrub Mark} = 0.3665$

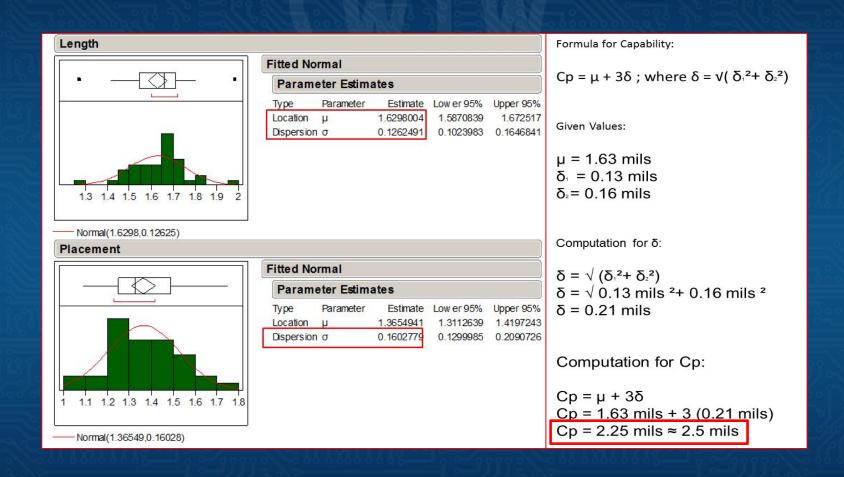
Capability =
$$1.74 + 3(0.3665)$$

Capability = 2.84 mils
$$\approx$$
 3 mils

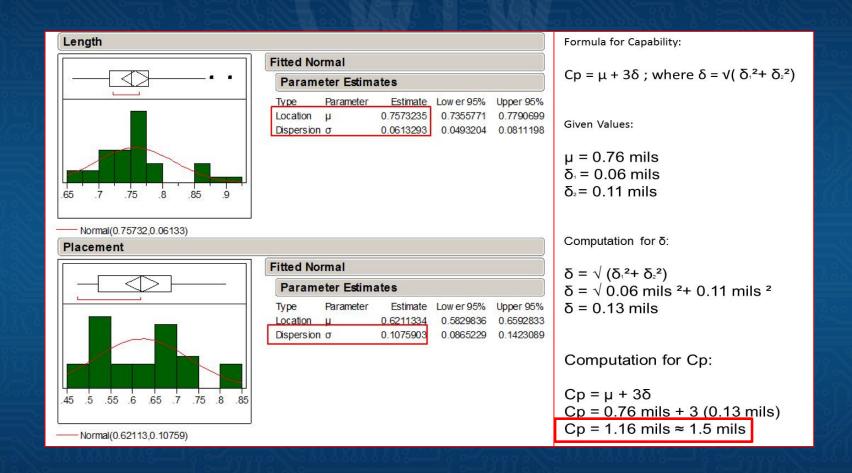
III. New Prober Tandem with Blade Type Needle



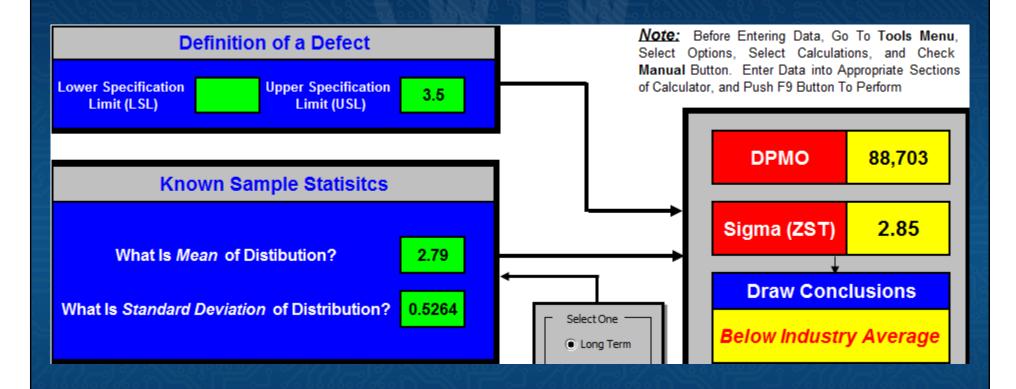
IV. New Prober Tandem with Epoxy Type Needle



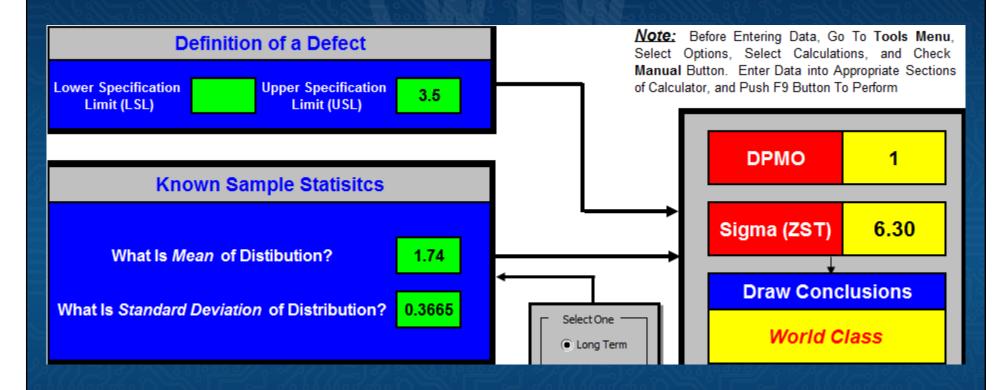
V. New Prober Tandem with Vertical Type Needle



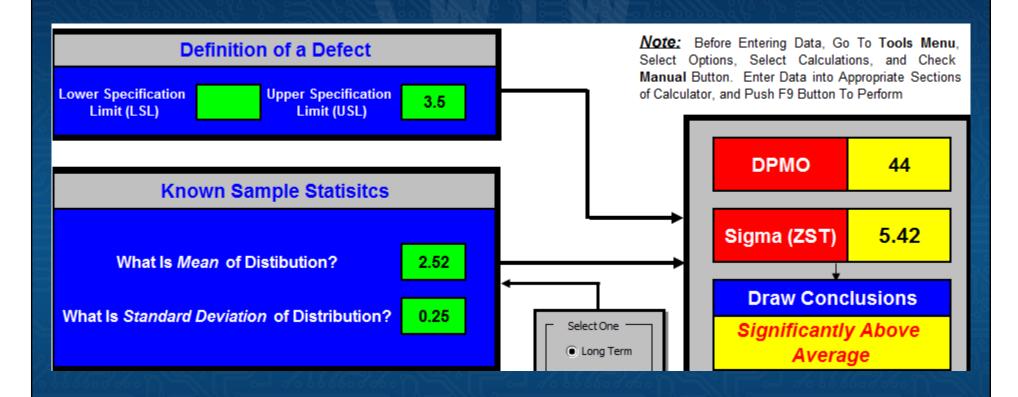
I. Old Prober Tandem with Blade Type Needle



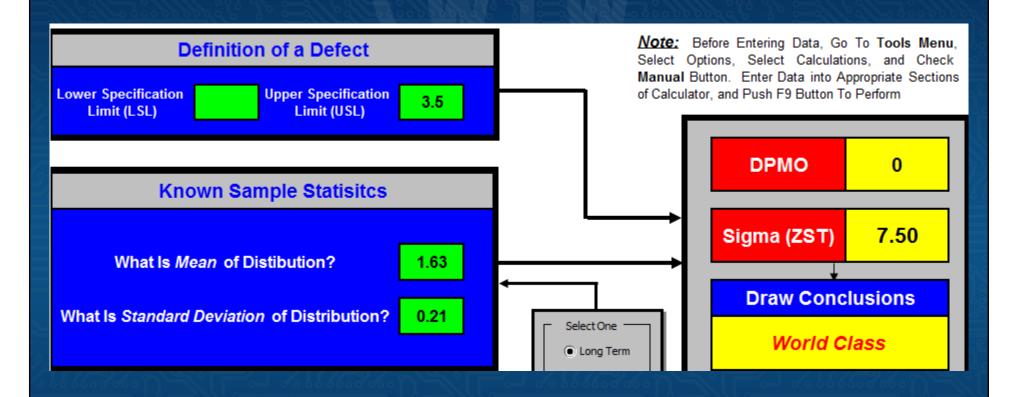
II. Old Prober Tandem with Epoxy Type Needle



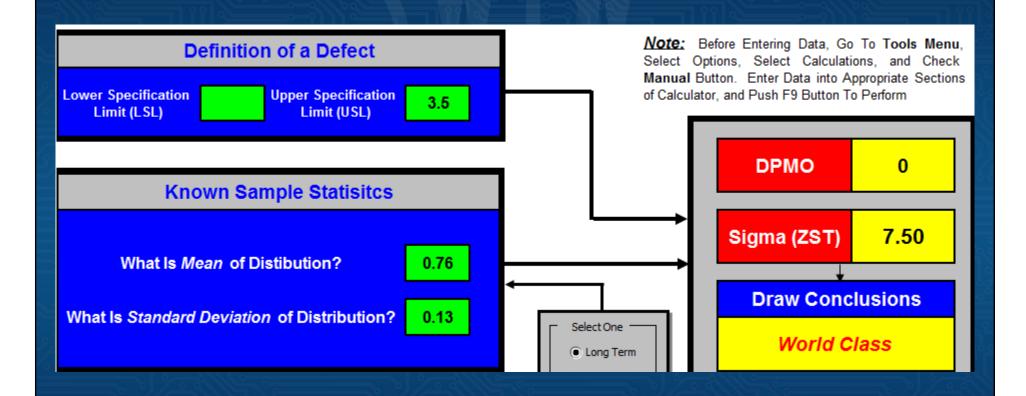
III. New Prober Tandem with Blade Type Needle



IV. New Prober Tandem with Epoxy Type Needle



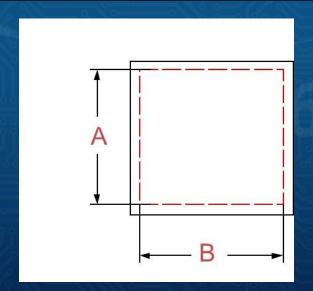
V. New Prober Tandem with Vertical Type Needle



Summary



Minimum Bond Pad Size Opening Capability												
Prober	Needle Type	Probe marks Size (x)	3 Sigma (Placement and Length)	A	В	∑ - Level	DPMO					
Old	Blade Type (1.5 mils)	2.79 mils	1.6 mils	4.39 mils	4.39 mils	2.85	88703.00					
OCOIGO	Epoxy Type (1 mil)	1.74 mils	1.1 mils	2.84 mils	2.84 mils	6.30	1.00					
	Blade Type (1.5 mils)	2.51 mils	0.74 mils	3.25 mils	3.25 mils	5.42	44.00					
New	Epoxy Type (1 mil)	1.63 mils	0.63 mils	2.25 mils	2.25mils	7.50	0.00					
	Vertical Probe (2.5 mils)	0.9 mils	0.36 mils	1.27 mils	1.27 mils	7.50	0.00					



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Summary

Capability Study:



- ✓ Old Prober tandem with Blade Type needle minimum bpo = 4.39 mils.
- ✓ Old Prober tandem with Epoxy Type = 2.84 mils.
- ✓ New Prober tandem with Blade Type = 3.25 mils.
- ✓ New Prober tandem with Epoxy Type = 2.25 mils and for New Prober tandem with Vertical Probe = 1.27 mils.

Sigma Assessment:

- ✓ Old Prober tandem with Blade Type needle zigma = 2.85 which has an expected defect per million opportunity = 88703.
- ✓ Old Prober tandem with Epoxy Type needle zigma = 6.30 which has an expected dpmo = 1.
- ✓ New Prober tandem with Blade Type needle zigma = 5.46 which has an expected dpmo = 37.
- ✓ New Prober tandem with Epoxy Type or Vertical Probe zigma level = 7.5 which has an expected = 0.

Follow-On Work

- For new product development, Wafer Probe Equipment capability in terms of placement and stepping accuracy should be consider primarily. Current trend of technology causes the Die Size shrunk. BPO becomes smaller and smaller.
- ➤ Probe Technology should also be considered. A wide spread variety of Probe Technology such as Cantilever, Buckling Type, Cobra and Pogo can be chosen depending on the current process requirement and what the customer needs.
- MPCPS should be done on every New Product/Process. This is an anticipation of risk that prevents the issue during the Production Run that cost a lot. Solving the problem at the source is much cheaper.

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